Serial No.: 09/902,429

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Case No: F0588



THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of: Qi Xiang

Serial No.: 09/902,429

Filing Date: July 10, 2001

For: SILICON ON INSULATOR FIELD EFFECT TRANSISTOR WITH

HETEROJUNCTION GATE.

Examiner: Laura M. Schillinger

Art Unit: 2813

Box Non Fee Amendment Assistant Commissioner for Patents Washington, D.C. 20231

RESPONSE TO OFFICE ACTION DATED MARCH 19, 2002

Examiner:

The applicants respectfully request favorable reconsideration of the application in view of the following amendments and comments.

AMENDMENTS

IN THE CLAIMS:

Please add new claims 22-27 as follows:

(New) The transistor structure of claim 1, wherein the gate extends the entire length of the channel region between the source region and the drain region.